

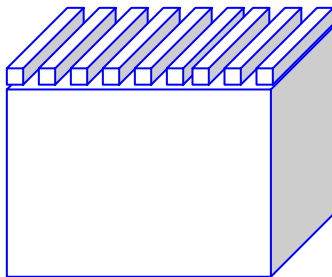


AccuSolve

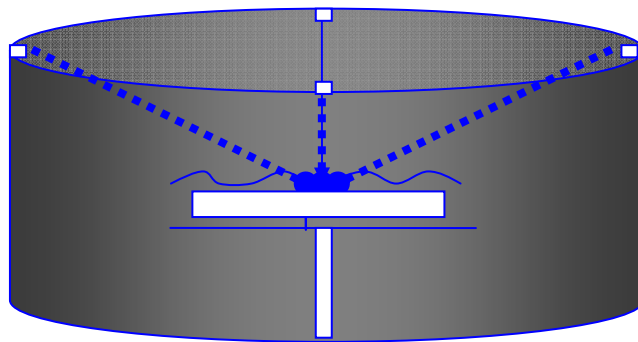
Spray-EC photoresist stripper for advanced Photomask processing

Application – Photomask photoresist stripping / removal process.

UV Module



Solvent Processing Module



概要
Overview

プロセス
Process

システム
SYSTEM

その他
Other

In Brief: Utilizing Ethylene-Carbonate (abbr.:EC) which a heated low volatility, biodegradable solvent in a spray processor configuration, photoresist is effectively removed from post etch processed photomasks.

Features and Benefits

Feature	Benefit
"Safe" Solvent based process	<ul style="list-style-type: none"> • High Selectivity to Mask Materials • No Sulfates • Minimal Safety Requirements • Low Cost
Biodegradable	<ul style="list-style-type: none"> • No Chemical Disposal Stream
Integrated UV Capability	<ul style="list-style-type: none"> • Extends Post Etch Capabilities
Temperature Control	<ul style="list-style-type: none"> • Optimize Process Based on Resist Condition